



## ***Reduced Early Bird Fee until February 28, 2019***

### ***Registration is now open for **NIL**industrialday 2019***

Dear Sir/Madam,

We are pleased to inform you that the registration for the 9th edition of the **NIL**industrialday 2019 is now open with reduced early bird registration available until February 28, 2019. For registration click [here](#).

The conference will be **held March 28-29, 2019 at SuperC, Aachen, Germany**.

The **NIL**industrialday is the most important event for early adopters of NanoImprint Lithography (**NIL**). It offers ideal conditions for information exchange on an international level.

It supplements scientific conferences by bringing together leading researchers and industry, promoting the use of **NIL** and related technologies as means for volume manufacturing.

The **NIL**industrialday primarily addresses existing opportunities for the application of **NIL** and **NIL** related technologies as manufacturing technique.

**NIL**industrialday 2019 addresses the following specific areas of applications:

- **Mastering, 3D Patterning, Metrology**
- **Photonics**
- **Life Sciences**
- **Security Features**

The enormous potential which offers **NIL** for industrial use as production technology will be shown.

For more information on exhibition and sponsorship opportunities click [here](#). For further information and assistance email us at [nil@amo.de](mailto:nil@amo.de). We look forward to seeing you at **NIL**industrialday 2019.

This event will be organized by Michael Hornung (AMO GmbH, Conference Chair), Gabi Grützner (micro resist technology GmbH, Steering Committee), Michael Mühlberger (Profactor GmbH, Steering Committee)

If you need any further information please feel free to contact us.

Best Regards / Michael Hornung  
*On behalf of the local organizing committee*  
<http://www.nil-industrialday.org/>

## The NIL ID will feature contributions of the following companies:

ams AG  
CEA-Leti  
Dispelix Oy  
EPFL Ecole polytechnique fédérale de Lausanne  
EURECAT Centre Tecnològic de Catalunya  
EV Group  
GenISys GmbH  
GermanLitho GmbH  
IMRE Institute of Materials Research and Engineering  
Korea University - Department of Materials Science and Engineering  
Micronit Micro Technologies B.V.  
NIL Technology ApS  
SUSS MicroOptics SA.  
University of Glasgow - School of Engineering  
WaveOptics Limited  
Yole Développement

## Confirmed Exhibitors



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